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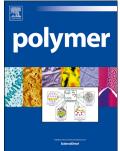
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Reversibility in Glass Transition Behavior after Erasing Stress

Induced by Spin Coating Process.

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KEYWORDS: Thin film, Glass transition temperature, Polystyrene, Supercritical CO₂, Confinement, Sample preparation history, Thermal dilatation, Ellipsometry.

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